

Embedded Systems: An Application-Centered Approach

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Two major sources of changing problems

New implementation technologies.

New applications.

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Evolution of computation

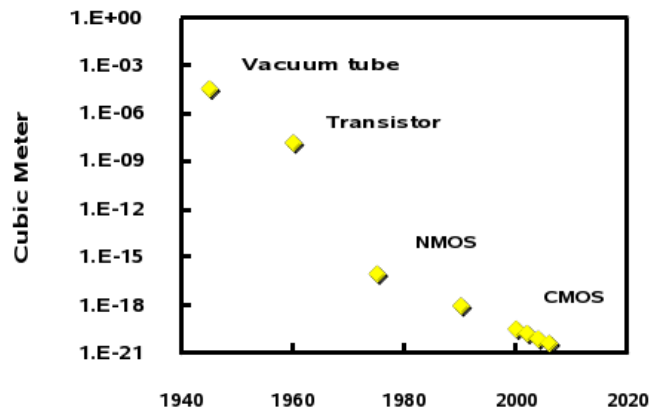
- 1800s: Mechanical
- Late 1800s–early 1900s: Electro-mechanical
- Early 1900s–mid 1900s: Vacuum tube electronic
- Mid 1900s–late 1900s: Bipolar (TTL)
- Late 1900s–early 2000s: MOS

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Impact of scaling on volume

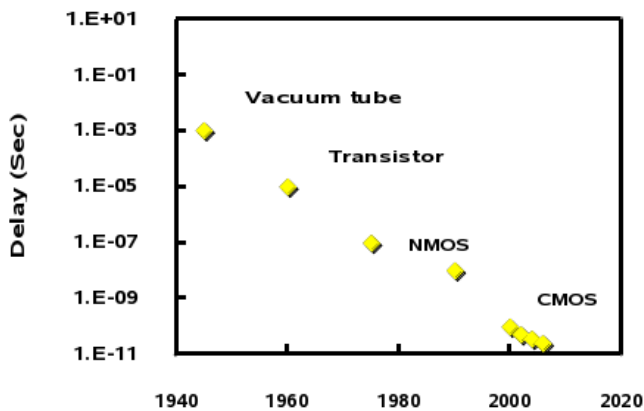


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Impact of scaling on delay

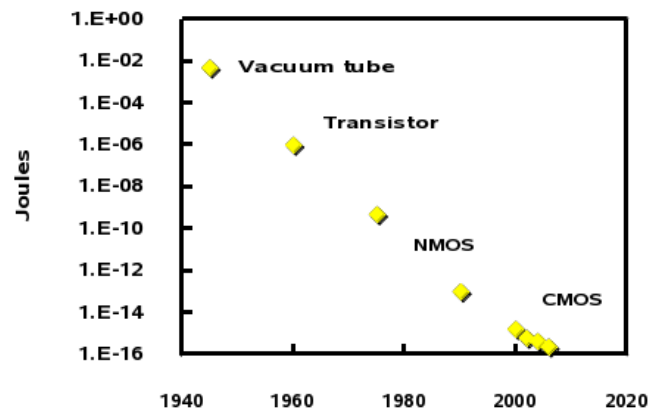


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Impact of scaling on energy consumption

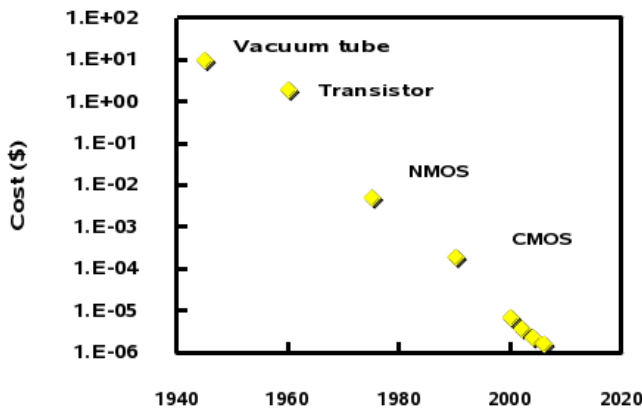


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Impact of scaling on price



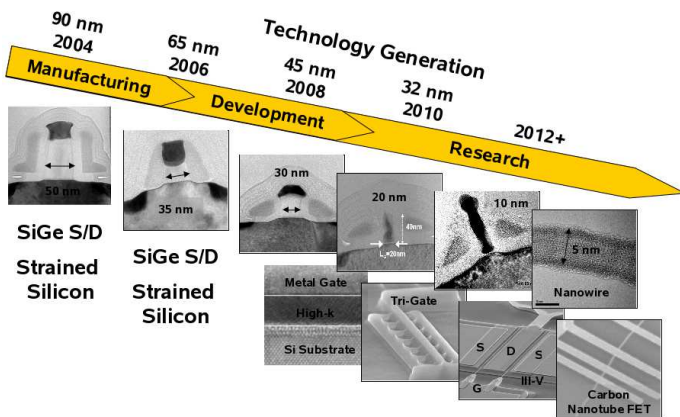
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Scaling trends

High Volume Manufacturing	2004	2006	2008	2010	2012	2014	2016	2018
Technology Node (nm)	90	65	45	32	22	16	11	8
Integration Capacity (BT)	2	4	8	16	32	64	128	256
Delay = CV/I scaling	0.7	~0.7	>0.7	Delay scaling will slow down				
Energy/Logic Op scaling	>0.35	>0.5	>0.5	Energy scaling will slow down				
Bulk Planar CMOS	High Probability			Low Probability				
Alternate, 3D etc	Low Probability			High Probability				
Variability	Medium			High		Very High		
Inter-lr dielectric k	~3	<3	Reduce slowly towards 2-2.5					
RC Delay	1	1	1	1	1	1	1	1
Metal Layers	6-7	7-8	8-9	0.5 to 1 layer per generation				

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Device trends



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Advantages of CMOS relative to prior technologies

- Performance
- Gain, low noise
- Area
- Massive integration
- Power
- Reliability
- Fabrication difficulty & cost

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Current status for CMOS

- 32 nm
- Power, thermal problems severe
- Fabrication cost per design high
- Potential reliability problems in future
- Soft errors
- Electromigration, dielectric breakdown, etc.
- Process variation
- Soon: Discrete dopant problems

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Computing trends applications

- Increased market volume and size for portable and embedded systems compared to general-purpose computers.
- Instructor's opinion: Embedded will grow in importance in the future.
- High-performance general-purpose computing will still matter.
- Much of the general-purpose computation will move to data centers.

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Advantages of alternative nanotechnologies

May allow continued process scaling after CMOS scaling impractical.

- Candidates
- Carbon nanotube
- Nanowire Single electron tunneling transistors

Comparison of nanoscale technologies

Table 59 Emerging Research Logic Devices—Demonstrated Projected Parameters

Device							
Type	FET [R] Si CMOS	1D structures CNT FET NW FET NW Inter-structure Coulomb nanostructure	Resonant Tunneling Devices RTD-FET RTF	SET	Molecular Crossover latch Molecular transistor Molecular QCA	Ferromagnetic logic Moving domain wall M-QCA	Spin transistor
Support Architecture	Conventional	Conventional and Cross-bar	Conventional and CSN	CSN	Cross-bar and QCA	Reconfigure logic and QCA	Conventional
Cell Size (optical pitch)	Projected 100 nm	Projected 100 nm [C] 500 nm <1.5 μm [D]	Projected 100 nm [C] 2 μm [H]	Projected 40 nm [L] 700 nm [M]	Projected 10 nm [Q] ~2 μm [R]	Projected 140 nm [U] 250 nm [V, W]	Projected 100 nm [C] 100 μm [Z]
Density (device/cm ²)	Projected 1E10	Projected 4.5E9	Projected 4.5E9	Projected 6E10	Projected 1E12	Projected 5E9	Projected 4.5E9
Switch Speed (device/cm ²)	Demonstrated 2.9E8	Demonstrated 4E7	Demonstrated 1E7	Demonstrated 2E8	Demonstrated 2E7	Demonstrated 1.5E9	Demonstrated 1E4
Switch Speed (Dimensional)	Projected 12 THz	Projected 4.3 THz [G]	Projected 1E THz [I]	Projected 10 THz [M]	Projected 1 THz [Q]	Projected 1 GHz [U]	Projected 40 GHz [V]
Switch Speed (Dimensional)	Projected 1 THz	Projected 200 MHz [F]	Projected 700 GHz [J]	Projected 2 THz [N]	Projected 100 Hz [R]	Projected 30 Hz [W]	Projected Not known
Circuit Speed	Projected 61 GHz	Projected 61 GHz [C]	Projected 61 GHz [C]	Projected 1 GHz [L]	Projected 1 GHz [Q]	Projected 10 MHz [U]	Projected Not known
Circuit Speed (Dimensional)	Projected 5.6 GHz	Projected 220 Hz [G]	Projected 10 GHz [I]	Projected 1 MHz [M]	Projected 100 Hz [R]	Projected 30 Hz [V]	Projected Not known
Switching Energy, J	Projected 3E-18	Projected 3E-18	Projected >3E-18	Projected 1e-16 [L] [>1.5e-16] [O]	Projected 5E-17 [Q]	Projected ~1E-17 [U]	Projected 3E-18
Switching Energy, J (Dimensional)	Projected 1E-16	Projected 1E-11 [G]	Projected 1E-13 [K]	Projected 8e-16 [P] [>1.3e-16] [O]	Projected 3E-7 [R]	Projected 6E-18 [W]	Projected Not known
Binary Throughput (Dimensional)	Projected 238	Projected 238 [C]	Projected 238 [C]	Projected 19	Projected 1000	Projected 5E-2	Projected Not known
Operational Temperature	Demonstrated 1.5	Demonstrated 1E-6	Demonstrated 0.1	Demonstrated 2E-4	Demonstrated 2E-9	Demonstrated 5E-8	Demonstrated Not known
Materials System	RT Si	RT Si, Ge, Bi-V, In ₂ O ₃ , ZnO, TiO ₂ , SiC	4.2 – 300 K Si-Ge	20 K [L]	RT	RT	RT
Research activity [A]		88	88	65	204	25	102

Credit to ITRS'05 report on Emerging Research Devices.

Carbon

allotropes

- diamond
- graphite
- carbon nanotube
- Fullerene

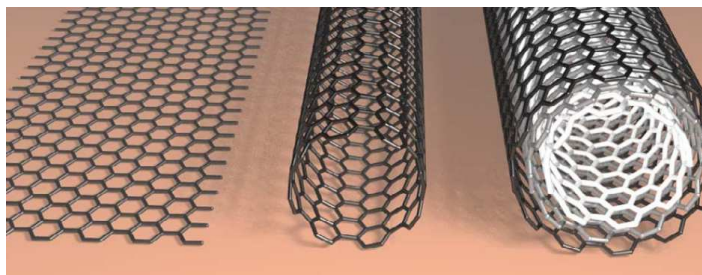
applications

- aerospace (rocket, aircraft)
- automotive (car)
- transportation (bicycle)
- nanotechnology (circuit, source)

CNT history

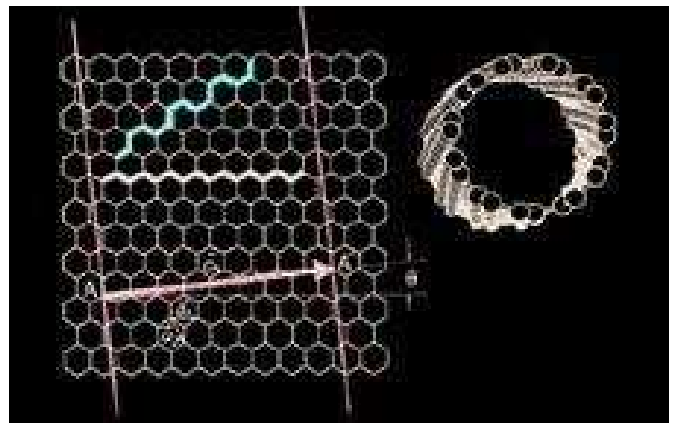
- 1880: Edison's original carbon-filament lamp (US Patent 223898)
- 1985: Discovery of Fullerenes (Smalley)
- 1991: Nanotubes discovered at NEC, by Japanese researcher Dr. Sumio Iijima
- 1998: F/A-18 Hornet: The first aircraft with carbon fiber wings
- 2001: Carbon nanotube transistor based logic-performing ICs (IBM)
- 2002: Carbon nanotubes in interconnect applications (Kreidl, Infineon)

CNT classes



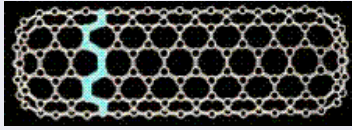
Graphene Single-walled CNT Multi-walled CNT

Chirality

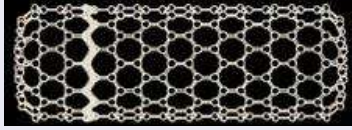


Metallic and semiconducting CNTs

Armchair (metallic)



Zigzag (semi-conducting)



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CNT properties

- Metallic or semiconducting.
- Diameter: 0.4–100 nm.
- Length: up to millimeters.
- Ballistic transport.
- Excellent thermal conductivity.
- Very high current density.
- High chemical stability.
- Robust to environment.
- Tensile strength: 45 TPa.
 - Steel is 2 TPa.
- Temperature stability
 - 2,800°C in vacuum.
 - 700°C in air.

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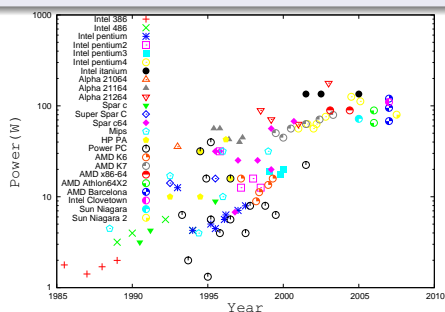
CNTs compared with Cu

Property	CNT	Cu
Max I dens. (A/cm ²)	> 1 × 10 ⁹ (Wei et al., APL'01)	1 × 10 ⁷
Thermal cond. (W/mK)	5,800 (Hone et al., Phy Rev B'99)	385
Mean free path (nm)	> 1,000 (McEuen et al. T Nano'02)	40

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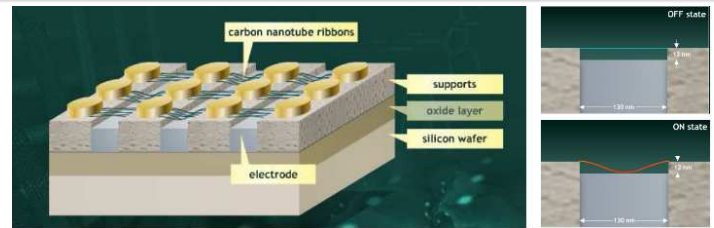
Power challenges

High-performance applications: energy cost, temperature, reliability
Portable embedded systems: battery lifetime



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NRAM



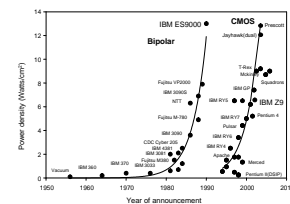
- Uses Van der Waals forces.
- Non-volatile.
- SRAM-like speed.
- DRAM-like density.
- Ready for market in 2007 (and 2008, and 2009, and 2010, and 2011).
- IEEE Spectrum loser of the year. Why?

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What does history teach us about power consumption?

Device innovations have been the most effective method

- Vacuum tube to semiconductor device in the 1960s
- Bipolar device to CMOS transistor in the 1990s



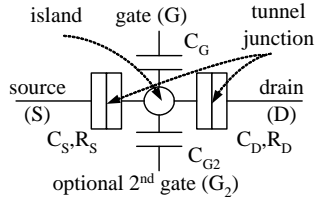
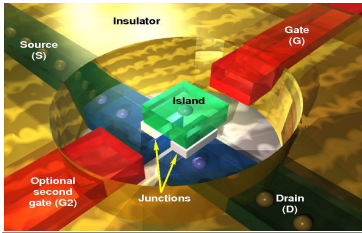
Based on diagram by C. Johnson, IBM Server and Technology Group

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Single electron tunneling transistor structure

Device structure

- Island, terminals (source, drain, gate)
- Electron tunneling through tunneling junctions



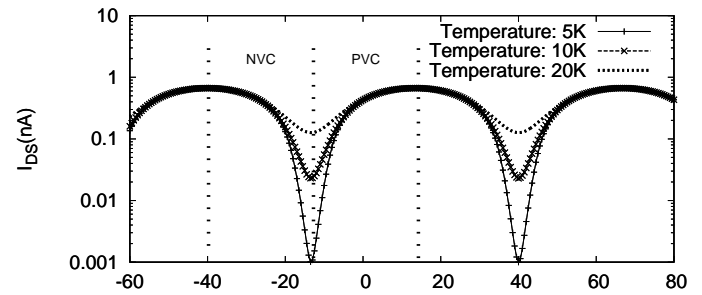
C_G :gate capacitance
 C_{G2} :optional 2nd gate capacitance
 C_S :source tunnel junction capacitance
 C_D :drain tunnel junction capacitance
 R_S :source tunnel junction resistance
 R_D :drain tunnel junction resistance

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Single electron tunneling transistor behavior

Physical principles

- Coulomb charging effect governs electron tunneling
- Coulomb blockade $V_{GS} = me/C_G$, $m = \pm 1/2, \pm 3/2, \dots$ OFF, $m = 0, \pm 1, \pm 2, \dots$ ON



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SET properties and challenges

Ultra low power

- Projected energy per switching event (1×10^{-18} J)

Room temperature and fabrication challenge

- Electrostatic charging energy must be greater than thermal energy
- $e^2/C_\Sigma > k_B T$
- Requires $e^2/C_\Sigma > 10k_B T$ or even $e^2/C_\Sigma > 40k_B T$

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SET properties and challenges

Performance challenge

- Electrons must be confined in the island
- $R_S, R_D > h/e^2$, $h/e^2 = 25.8 \text{ k}\Omega$
- High resistance, low driving strength

Reliability concerns

- Tunneling between charge traps cause run-time errors
- Unknown before fabrication
- Device technology: Improved by silicon islands
- Reliable design: Post-fabrication adaptation
- Run-time error correction

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Summary

- CMOS will be mainstream for years to come, but not forever.
- The meaning of integrated circuits will change in the future.
- Circuit and logic design fundamentals will still apply.
- Some rules, e.g., difficulty of implementing non linearly separable functions, may change.
- You will each need to adapt as the rules governing device behavior change, but this will be much faster now that you have a foundation.

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